

Express Mail Label No.: EL 640 011 113 US

IN THE U.S. PATENT AND TRADEMARK OFFICE

April 3, 2001

Applicant(s) : Toshiaki MOTONAGA et al.
For : HALFTONE PHASE SHIFTING PHOTOMASK AND
BLANKS FOR HALFTONE PHASE SHIFTING
PHOTOMASK THEREFOR AND A METHOD FOR FORMING
PATTERN BY USING THE HALFTONE PHASE
SHIFTING PHOTOMASK

Atty. Docket No.: OPS Case 529

Assistant Commissioner for Patents
Washington, DC 20231

AMENDMENT BEFORE FIRST OFFICE ACTION

Sir:

Prior to issuance of the first Office Action in the
above-identified application, kindly enter the following:

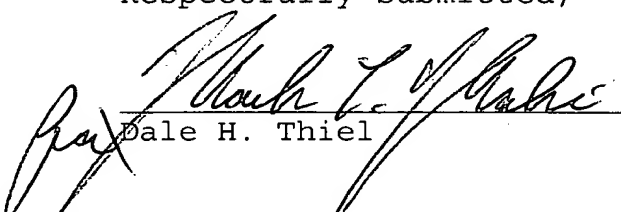
IN THE SPECIFICATION

Paragraphs 0029, 0030, 0035, 0036 and 0038-0040 are
amended as indicated in the attached marked-up copy. Pursuant
to 37 CFR §1.121, replacement pages with the amended
paragraphs are attached.

REMARKS

The above amendment is being made to conform the brief
descriptions of Figs. 1, 2, 5, 7, 8 and 10-12 to the drawing
sheets.

Respectfully submitted,


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DHT/jp

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Reg. No. 24 323

Reg. No. 25 072

Reg. No. 22 724

Reg. No. 32 549

Reg. No. 36 589

Reg. No. 31 257

Reg. No. 24 949

Reg. No. 40 694

Reg. No. 36 328

Encl: Marked-up paragraphs 0029, 0030, 0035, 0036
and 0038-0040 (2 pages)

Replacement paragraphs 0029, 0030, 0035, 0036
and 0038-0040 (2 pages)

112.9803